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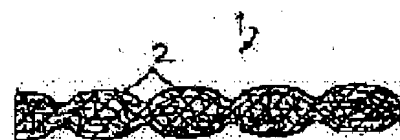
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(54) FACE WASHING CLEANER

(57) Abstract:

PURPOSE: To efficiently remove the dirt adhered to the skin or an aged horny substance, and apply a lotion thereto to moisten the skin.

CONSTITUTION: A polygonal section extra fine fiber nonwoven fabric 1 is impregnated with a lotion containing a moisture retaining agent, and as an additive constituting factor, protruding parts 2 are provided on the wiping surface of the nonwoven fabric 1. Since the section of the polygonal section extra fine fiber forms an extra fine soft edge-like part such that about 100 to 300 pieces are present in a length of 1mm, not only dust or fat but also an aged horny substance which could not be removed by a conventional nonwoven fabric can be softly removed without damage, and a moisture retaining agent is applied to moisten the skin. Thus, beauty effects such as prevention of pimple and promotion of regeneration of skin can be provided. Since dust sweeping function is further generated in the edge-like part by forming the protruding parts on the wiping surface, and dust storing function can be exhibited in the adjacent recessed parts, the dust adhesion to the edge-like parts of the protruding part forming the wiping surfaces is reduced, and the removing function of fat and aged horny substance can be effectively continued.



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